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Introduction 1.

At present, sustainable and renewable energy alternatives are highly sought after to address the detrimental climate turmoil caused by decades of greenhouse gas emissions.1-3 Hydrogen (H_2) fuel energy is thought to be one of the alternative solutions in this regard.⁴ However, conventional H₂ fuel production, including high-temperature and pressure steam methane reforming (SMR), biomass pyrolysis, and coal gasification (~5 MPa), emits CO₂ and is inherently costly.⁵ Semiconductor-based photocatalytic water splitting (SPWS) provides more economical and CO₂- free H₂ gas.⁶ In SPWS, the semiconductor photocatalysts react with water and produce hydrogen (H₂) and oxygen (O_2) through the hydrogen evolution reaction (HER) and oxygen evolution reaction (OER), respectively. In 1972, the photocatalyst properties of TiO₂ were first reported; which provoked growing attraction in this field to find novel semiconductor photocatalysts from bulk to nano.6,7 However,

Excellent photocatalytic properties in 2D ZnO/SiC van der Waals hetero-bilayers: water-splitting H₂fuel production

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This research unravels the photocatalytic properties of a 2D ZnO/SiC van der Waals hetero-bilayer for potential water-splitting applications by first-principles calculations. Four unique stacking patterns are considered in studying the electronic and optical properties in the presence and absence of biaxial external strain. For pattern-I and II, large negative binding energy and positive phonon frequencies are observed, denoting chemical and mechanical stabilities. Under the HSE-06 pseudo potential, the calculated bandgap value for pattern-I and II reaches 2.86 eV and 2.74 eV, respectively. 2D ZnO/SiC shows a high absorption coefficient ($\sim 10^5$ cm⁻¹). The absorption peak under biaxial strain could reach \sim 3.5 times the peak observed under unstrained conditions. Under strain, a shift from compressive to tensile biaxial strain (-6% to 6%) results in a bandgap decrease from 3.18 eV to 2.52 eV and 3.09 eV to 2.43 eV, for pattern-I and II, respectively. The observed strain-driven kinetic overpotential for 2D ZnO/ SIC pattern-I and II easily engenders photocatalytic redox reactions. The excellent mechanical durability and strain-driven large kinetic overpotential suggest 2D ZnO/SiC heterobilayers as a prospective material for water-splitting H₂-fuel production.

> finding new materials that meet all the multi-facet desires of an efficient photocatalyst is still a demanding challenge.

> Of late, graphene and graphene-like nanostructures are widely reported for their unprecedented feasibility in efficient photocatalysis.8-10 Graphitic metal free g-C3N4 demonstrates a hydrogen yield of \sim 3.2 µmol h⁻¹ g⁻¹ at 420 nm wavelength of photons.11 Pt co-catalyst in g-C3N4 outperforms the H2 yield by \sim 35 times (\sim 106 µmol h⁻¹ g⁻¹) as in the g-C₃N₄.¹² Bandgapengineered graphene in the existence of a co-catalyst provides \sim 1050 µmol h⁻¹ g⁻¹ of H₂ yield.¹³ Prominent transition metal dichalcogenides (TMDs); MoSe₂, MoS₂, and WS₂, synthesized experimentally, mark up \sim 62 000, \sim 26 000, and \sim 2570 µmol h⁻¹ g⁻¹ of hydrogen yield, correspondingly.^{14,15} Widely tailorable bandgap and peak-absorption near-visible spectrum makes InX (X = S, Se, Te) (\sim 2.22–3.19 eV) and GaX (X = S, Se, Te) (~2.20-2.71 eV) as efficient photocatalysts.¹⁶ Photocatalytic activities increase in nanostructure materials due to large surface zone, higher carrier mobility, and higher reaction sites. A higher reaction rate thus follows with a larger carrier transfer. However, to make practice use of the higher reaction rate, the charge carriers are required to spatially separate externally. Technique involving vdW stacking and external biaxial strains incorporation improves carrier generations and their spatial separation. Moreover, recent investigation has demonstrated lucrative properties in vdWs structure for possible application in PWS, which encircles properties like bandgap engineering,

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Fig. 1 Relaxed structures of (a) 2D-ZnO, (b) 2D-SiC, (c) pattern-I, (d) pattern-II, (e) pattern-III, and (f) pattern-IV. Violet, deep red, cyan, and golden yellow spheres represent Zn, O, Si, and C, respectively.



Fig. 2 Layer spacing-dependent binding energy for the three 2D ZnO/ SiC vdW HBLs.

enhanced optical absorption, in-plane and out-of-plane thermal transport, and efficient spatial carrier separation capability.^{17–26}

In recent years, a number of studies for enhancement of photocatalytic water-splitting performance cogitating broad bandgap vdWHs have been reported.27-30 Studies on vdWHs, including BP/GaN,³¹ ZnO/MoS₂,³² GaN/GeC,^{33,34} ZnO/WSe₂,³⁵ blue phosphorene/g-GaN,³⁶ graphene/g-C₃N₄,³⁷ GeC/SiC,³⁸ CdO/CdS,³⁹ h-BN/C₂N,⁴⁰ ZnO/GeC,⁴¹ and blue phosphorene/ MoS₂,⁴² have demonstrated unique tunable electronic properties, improved optical absorbance, and efficient carrier separation capability, facilitating PWS. However, the optoelectronic characteristics of single-layer ZnO in its nanostructured form are still scarce though the bulk is widely studied. 2D ZnO, having high-mechanical and chemical stabilities show unique optoelectronic properties and tunability, make it a suitable candidate for PWS. Also, the stacked 2D ZnO with other 2D structures could enhance the PWS performance. 2D SiC is also another widely studied vdW stacked material that has a substantial impact on improving PWS performance. Prior 2D SiC-based device applications and

Table 1 The geometry-relaxed lattice constant a (Å), bond length d_B (Å), interlayer binding energy E_b (meV), interlayer spacing d (Å), the computed bandgap using the PBE and HSE-06 functional are E_g (PBE) (eV) and E_g (HSE-06) (eV), respectively

Pattern	a (Å)	$d_{ m B}$ (Å)	$E_{\rm b}$ (meV)	<i>d</i> (Å)	$E_{\rm g}$ (PBE)	$E_{\rm g}$ (HSE-06)
2D-ZnO	3.246	1.874	_	_	1.71	2.92
2D-SiC	3.135	1.794	_	_	2.51	3.22
2D ZnO/SiC pattern-I	3.224	_	-135.5	3.54	1.76	2.86
2D ZnO/SiC pattern-II	3.231	_	-132.2	3.21	1.67	2.74
2D ZnO/SiC pattern-III	3.234	_	-96.8	3.06	_	_
2D ZnO/SiC pattern-IV	3.226	_	-87.6	3.15	_	_

Paper

their unique stability remark its potentiality for PWS.⁴³ Generally, 2D SiC shows direct bandgap and low visible light absorption, while on stacking with other monolayers the optoelectronic properties are widely altered and enhancement in optical absorption in visible spectrum is found.⁴⁴ Thus, a vdW hetero-bilayer (HBL) composed 2D ZnO and 2D SiC is

expected to demonstrate excellent photocatalytic features. Nevertheless, there is absence of detailed previous study on the 2D ZnO/SiC vdWs properties for PWS application from our thoughtful. Thus ZnO/SiC vdW hetero-bilayer needs an indepth strain-driven study to highlight the intrinsic and enhanced tunable optoelectronic photocatalytic properties.



Fig. 3 The phonon band dispersions for (a) 2D-ZnO, (b) 2D-SiC, (c) pattern-I, (d) pattern-II, (e) pattern-III, and (f) pattern-IV.

Herein, 2D ZnO/SiC vdW HBL is widely investigated through density functional theory (DFT) for photocatalytic H_2 -fuel generation. Four stacked patterns of 2D ZnO/SiC vdWHs are investigated upon which two structures are underscored for excellent photocatalysis applications. The phonon dispersion is calculated to know the dynamical stability of the materials. Strain-induced electronic and optical properties of the material are also investigated and reported. Our intensive studies suggest that the 2D ZnO/SiC in its intrinsic and tuned form demonstrates promising photocatalytic performance and thus, could be considered an efficient photocatalyst for H_2 -fuel production.

2. Methodology

The Quantum Espresso package,^{45,46} norm-conserving (NC) pseudopotentials,^{47,48} and the Perdew-Burke-Ernzerhof (PBE)⁴⁹ are employed as exchange-correlation functional to

perform the density functional theory calculation. The twoatom basis unit cell of 2D ZnO and 2D SiC consists of the atoms of Zn [3d¹⁰ 4s²], O [2s² 2p⁴], C [2s² 2p²], and Si [3s² 3p²]. The kinetic energy cut-off (charge density cut-off) was set to 400 eV (850) eV for 2D ZnO, 2D SiC, and the four stacked vdWHs. The tolerance limit of self-consistent function (SCF) was set $\sim 10^{-6}$ a.u. The force convergence cut-off was set to 10^{-3} a.u for geometry relaxation of the proposed structures. The first Brillouin zone was integrated by $8 \times 8 \times 1$ gammacentered Monkhorst–Pack k-mesh grid.50 A 20 Å vacuum spacing was allowed to reduce the image-layer correlation. Conventional GGA-PBE functional predicts underestimated bandgap for a semiconductor that's why Heyd-Scuseria-Ernzerhof (HSE-06) nonlocal functional was incorporated to precise prediction of the electronic gap in the band dispersion of the monolayers as well as the vdWHs.51 Along with it, vdW corrected DFT-D3 method from Grimme was applied for including the vdW interaction amid the monolayers.52



Fig. 4 The electronic band structures for (a) ZnO monolayer, (b) SiC monolayer (2D-SiC), and for the 2D ZnO/SiC vdW HBLs (c) pattern-I, and (d) pattern-II using the PBE and HSE-06 functional.

Paper

Dynamical stability predicting phonon dispersions is computed by the density functional perturbation theory (DFPT) where pseudopotential as NC-PBE is used with $4 \times 4 \times 4$ dynamical matrix.⁵³ The optical phonon modes separation (transverse and longitudinal) was defined by the Born and Huang system.⁵⁴ The complex dielectric function was employed to calculate the optical properties. The time-resolved perturbation theory in its first order was incorporated with an MP kmesh grid of $10 \times 10 \times 1$.⁵⁵ The guiding formula of the dielectric function is $\varepsilon(\omega) = \varepsilon_1(\omega) + j\varepsilon_2(\omega)$, where ε_1 and ε_2 are the real and the imaginary parts of the function. Adding the empty states, the imaginary part of the dielectric function is defined by,⁵⁶

$$\begin{split} \varepsilon_{2}^{\alpha\beta}(\omega) &= \frac{4\pi^{2}e^{2}}{\varOmega} \frac{\lim_{q \to \infty} 1}{q^{2}} \sum_{c,v,k} 2\omega_{k} \delta(\varepsilon_{ck} - \varepsilon_{vk} - \omega) \times \left\langle \mu_{ck+qe_{\alpha}} \middle| \mu_{vk} \right\rangle \\ & \times \left\langle \mu_{vk} \middle| \mu_{ck+qe_{\beta}} \right\rangle \end{split} \tag{1}$$

where, c = states for conduction band; $\nu =$ states for valence band; $\mu_{ck} =$ periodic cell wave function at the *k*-point.

3. Results and discussion

First, the structural characteristics of the proposed ZnO/SiC vdW-HBLs are investigated. The geometry relaxed 2D ZnO, SiC, and four different stacked patterns (pattern-I, II, III, and IV)



Fig. 5 (a) The band configurations for 2D-ZnO, 2D-SiC, pattern-I, and pattern-II for photocatalytic water splitting. (b) Graphical representation of the spatial charge transfer in type-II 2D ZnO/SiC vdW heterostructure. Atomic orbital projected density of states, PDOS for (c) pattern-I, and (d) pattern-II, vdW heterostructure (HSE-06).

are presented in Fig. 1. The intrinsic 2D ZnO, and SiC are found in non-buckling two-dimensional (2D) hexagonal structures. Here, the calculated geometry relaxed bond length of ZnO is 1.875 Å and lattice constant, a=3.262 Å while 2D-SiC has 1.847 Å for bond length and 3.138 Å for the lattice constant. The results are closely matched with the previous studies.^{57,58} The four patterns were proposed by stacking a 2 × 2 2D-ZnO (a = b = 6.524 Å) layer above a 2 × 2 2D-SiC (a = b = 6.276 Å) monolayer with four unique patterns.

Due to having closely matched lattice parameters of ZnO and SiC lattice disparity between ZnO and SiC layers is found around ~3.3%, residing the maximum allowable 5% mismatch limit, calculated using the relation, $f = \frac{a_{\text{ZnO}} - a_{\text{SiC}}}{a_{\text{ZnO}}} \times 100$. The four stacking patterns are defined as pattern I, the Zn (O) atoms of the ZnO monolayer are located right above Si (C) of the bottom SiC; pattern II(III), Zn (C) atoms were at right on top of the Si atoms, but the C (Zn) atoms were fixed at the center of the hexagons and pattern IV, the Zn and O atoms of the ZnO monolayer are on right above C and Si, correspondingly, of the bottom SiC monolayer.

The interlayer binding energy is calculated by following the formula to predict the chemical formation probability of the stacked vdWs,

$$E_{\rm b} = E_{\rm ZnO/SiC} - E_{\rm ZnO} - E_{\rm SiC} \tag{2}$$

where, $E_{\text{ZnO/SiC}}$ denotes the total dispersion corrected energy of the HBL, E_{ZnO} and E_{SiC} , refers total energies of the 2D-ZnO and 2D-SiC monolayers, correspondingly. The interlayer distancedependent binding energies for the vdWs are exhibited in Fig. 2 for the two stable vdW HBLs. Table 1 summarizes the optimized-crystal lattice parameters, binding energy amid layers, layer spacing, and bond distances for 2D-ZnO, 2D-SiC, and the HBL patterns I-IV. The pattern I is the most favorable in energy as having the lowest binding energy.

The DFPT-based phonon dispersion predicts the dynamical stability of the projected patterns. The negative phonon frequencies found for patterns III and IV, as depicted in Fig. 3, suggest the dynamical instability of the materials. The other structures, *i.e.*, the monolayers and pattern-I & II, having nonzero phonon frequencies show dynamical stability. The longitudinal acoustic (LA), transverse acoustic (TA), and flexural acoustic (ZA) modes are found the lowest value at the Γ point. The optical phonon modes LO and TO are found non-degenerate at Γ for the stable vdW-HBLs. The maximum frequency of the LO phonon mode is 921 cm⁻¹ (923 cm⁻¹) for pattern I (pattern II).

Now, the electronic characteristics of 2D-ZnO, 2D-SiC, and the four stacked vdWs are calculated through DFT. The electronic dispersion at GGA-PBE and HSE-06 levels for intrinsic ZnO and SiC monolayer is calculated and demonstrated in Fig. 4, in red and blue lines, correspondingly. The calculated direct bandgap is found \sim 2.92 eV and 3.234 eV at the HSE-06 level for ZnO and SiC monolayer. The bandgap and nature values of ZnO, and SiC monolayer (Fig. 4(a)) and (Fig. 4(b)) are in well-agreement with earlier studies.^{58,59} The band structure of the two stable vdW patterns (pattern-I, and pattern-II) are presented in Fig. 4(c) and (d), in both GGA-PBE and HSE-06 functional marked in the red and blue line, correspondingly. The ZnO monolayer has a direct bandgap at the gamma point while the SiC monolayer has a direct bandgap at *K*-point (Fig. 4(b)). However, both stable stacked patterns have *G*-point direct gap, suggesting the photocatalytic application suitability. Patterns I and II show 2.86 eV and 2.79 eV bandgap, respectively calculated using HSE-06 functional. Table 1 summarizes the different bandgap values at GGA-PBE and HSE-06 levels for the monolayers and vdWHs. To find photocatalytic kinetic overpotential, the band edge energies compared to the vacuum are needed to be calculated. Using HSE-06 bandgaps the photocatalytic band ends are formulated as,

$$E_{\rm CBE} = X - \frac{E_{\rm g}^{\rm HSE}}{2} \tag{3}$$

$$E_{\rm VBE} = X + \frac{E_{\rm g}^{\rm HSE}}{2} \tag{4}$$

The X = Mulliken electro-negativity's geometric mean of the comprising atoms. The attained X for ZnO (SiC) monolayer is 5.75 eV (5.48 eV). The band edges for all the ZnO/SiC HBLs are



Fig. 6 Charge density difference plot of (a) pattern-I and (b) pattern-II of 2D ZnO/SiC heterobilayer structure. Red and green refer to charge accumulation and depletion, correspondingly. (c) The electrostatic potential of 2D ZnO/SiC heterobilayer structure.

also investigated for photocatalytic H_2 production watersplitting capability.

Generally, semiconductors-based photocatalytic water splitting (SPWS) requires certain conditions to be met up:³⁴ (i) the conduction band end energy level (CBE) needs to be higher or same as -4.44 eV (reduction potential) for HER (H⁺/H₂), (ii) the valence band end (VBE) energy level needs to be lower or same as -5.67 eV (oxidation potential) for OER (O₂/H₂O), (iii) at least \sim 1.23 eV of the bandgap is needed for the semiconductor, (iv) the semiconductor needs to possesses high-absorption in near ultra-violet (NUV), and visible spectrum, and (v) to promote H₂ formation, the semiconductor must have high surface area for redox reaction.

The calculated band edges of ZnO, SiC, and ZnO/SiC vdW-HBLs are presented in Fig. 5(a). Also, the vdW HBLs show type-II bandgap as calculated in band-edges. In the monolayers and vdWHs, the conduction (valence) band edge is found greater (lower) than the potential of oxidation (reduction). Hence, the structures having adequate kinetic overpotential are promising for PWS. Additionally, the measured valence band offset (0.402 eV) and conduction band offset (0.015 eV) value is confirmed, showing carrier parting spatially. The concise carrier separation mechanism through the photo redox process is demonstrated in Fig. 5(b). The formation of the type-II bandgap is confirmed as the VBM and CBM of the SiC monolayer are below that of the ZnO monolayer. This results in the photogenerated electrons moving from ZnO to SiC monolayer strikes, surpassing conduction offset and contributing to HER to generate H_2 . Likely, the holes are moving toward ZnO from SiC and contribute to OER to form O_2 as depicted in Fig. 5(b). Among the two stable patterns, pattern-I is shown to be the most suited photocatalyst due to having a high band offset in redox potential. From the computed total and partial density of state (DOS) to show orbital contribution in total DOS as found in Fig. 5(c) and (d), in pattern I and II, the Zn-s-orbital contributes mainly to CBM while the VBM is primarily from O-s-orbital from ZnO monolayer. Thus both of them show a type-II bandgap.

The charge sweeping between the ZnO and SiC monolayers, the charge density difference (CDD) is calculated and presented in Fig. 6 for the two patterns, as formulated, $\Delta \rho_{\rm CDD} = \rho_{\rm HBL} - \rho_{\rm HBL}$ $\rho_{\rm ZnO} - \rho_{\rm SiC}$; where, $\Delta \rho_{\rm CDD}$ is the CDD; $\rho_{\rm HBL}$, $\rho_{\rm ZnO}$, and $\rho_{\rm SiC}$, mention the charge density (CD) of the studied HBL pattern, the ZnO monolayer, and the SiC monolayer. The charge addition is marked in blue, while charge depletion is marked in red. In both pattern-I (Fig. 6(a)) and pattern-II (Fig. 6(b)), the charge lessens from the Zn atoms and collects near the O atoms of the ZnO layer. A small quantity of charge also decreases near the C atoms of the SiC layer. Interestingly, the charges are accumulated in the ZnO monolayer in all the patterns, indicating that ZnO largely determines the properties of the heterobilayer. Moreover, the most electron transport is afforded by the ZnO layer, resulting in altering bandgaps for the heterobilayer while the SiC monolayer turns into a property tuner of the heterobilayers. In Fig. 6(c), the electrostatic potential for pattern-I and pattern-II is provided, which helps to predict the charge



Fig. 7 Electron localization function of (a) pattern-I and (b) pattern-II of 2D ZnO/SiC heterobilayer structure. The red overlayer refers to the localized electron.

polarities near the active sites of the monolayer surfaces. For each pattern, two negative electrostatic potential peaks are observed, one from the ZnO layer and one from the SiC layer. Electrostatic potential in ZnO being more negative refers that more electron appears on the ZnO layer; this could be due to the charge shift from the SiC layer to the ZnO layer. The potential difference between the two vertically stacked monolayer surfaces (ZnO and SiC) is 0.883 eV and 0.866 eV, respectively, for



Fig. 8 Strain-dependent (a) bandgap and band edge position for (b) pattern-I and (c) pattern-II 2D ZnO/SiC vdW HBLs using the HSE-06 functional.

Paper

pattern-I and pattern-II. Thus, ~0.9 eV of energy would suffice for an efficient charge transfer between the vertical layers. Fig. 7 demonstrates the electron localization function across the ZnO/ SiC heterobilayer pattern-I and pattern-II atoms. It is observed that comparatively higher localization appears in the proximity of oxygen (O) and carbon (C) atoms of the ZnO and SiC layer. The inherent electron affinity of O and C could be a crucial factor that pulls the localized σ -bonds' electrons formed through the covalent sp³ bonding of SiC and ZnO.

Altering electronic properties of the vdWHs, biaxial strain is a significant way. Therefore, the biaxial strain-induced electronic property is investigated. Here, the 2% incremental -6% to +6%strain range is considered. In Fig. 8(a) the strain-tuned bandgaps are shown. It is clear that a noticeable lowering of the bandgap is found from compressive to tensile strain application due to CBM and VBM moving on the Fermi level. This trend is found in both the PBE and HSE-06 levels of the bandgap values. This bandgap lowering facilitates high absorption in the visible spectrum due to the shifting of absorption peaks from UV to the visible spectrum, suitable for photocatalytic application. As strains tune the bandgap, the photocatalytic band edges are also calculated for strain-tuned bandgap value as seen in Fig. 8(b) and (c) for pattern-I and II. In the whole strain range, pattern-I has sufficient kinetic overpotential while pattern II has sufficient kinetic overpotential except at 6% tensile strain. These findings suggest that the proposed vdWHs, with a tunable photocatalytic feature, can be a potential candidate for PWS.

To study the optical features of the stable vdWHs, the firstorder DFPT is incorporated. The real and the imaginary parts, signifying the result of scattering and absorption are obtained through Kramers–Kronig conversion, and momentum matrix, correspondingly. The dielectric function defined by $\varepsilon(\omega) = \varepsilon_1(\omega)$ + $i\varepsilon_2(\omega)$, with angular frequency (ω) strikes it. While the absorption coefficient of the materials can be formulated by real and imaginary dielectric functions portions as,

$$\alpha(\omega) = \sqrt{2} \left(\sqrt{\varepsilon_1^2(\omega) + \varepsilon_2^2(\omega)} - \varepsilon_1(\omega) \right)^{1/2}$$
(5)

where ω means the photon frequency, and α is the absorption coefficient. The computed real and imaginary parts of the



Fig. 9 (a) The real, (b) imaginary parts of the dielectric function, and (c) absorption for pattern-I and pattern-II of 2D ZnO/SiC vdW HBLs.



dielectric function for 2D-ZnO, 2D-SiC, and the two HBLs are presented in Fig. 9. In both pattern-I, and II, a lack of negative share of the real dielectric function $\varepsilon_1(\omega)$ for the whole photon energy range, suggesting the material's pure semiconducting nature. Besides, due to bandgap modification, peaks close to the visible range are seen enhanced with positive $\varepsilon(\omega)$, suggesting enhanced absorption in the material.

Our proposed ZnO/SiC HBLs show an enhanced absorption peak as demonstrated in Fig. 9. The peak absorption is acquired $\sim 3.9 \times 10^5 \text{ cm}^{-1}$, and $4 \times 10^5 \text{ cm}^{-1}$, at 6.4 eV, and 6.5 eV, suitable for photocatalytic application.45 A large number of absorption peaks and high-intensity peaks mean high absorption, resulting in a more photo-generated carrier, a requirement for photocatalyst. Apart from this, a larger number of peaks, inferring, more carrier transition, predict high mobility of carrier. Furthermore, the visible peak is at (\sim 3.4 eV) of \sim 1 \times 10^5 cm^{-1} in the visible spectrum.

Introducing biaxial strain can shift the absorption peaks from UV to visible and render efficient utilization of solar spectra. Biaxial strain-induced optical absorption is thus investigated as exposed in Fig. 10 (a) and (b) for -6% to +6% biaxial strains. The absorption top-points are at ~410 nm, and ~415 nm, wavelength for pattern-I, and II, similarly, and outcome an absorption coefficient of ${\sim}7~{\times}~10^5~{\rm cm}^{-1},$ and ${\sim}7.2~{\times}~10^5~{\rm cm}^{-1}.$ Yet, compressive strains shift the absorption peak from UV to visible. Additionally, pattern-II shows the highest tuned due to applied biaxial strains. Moreover, a significant portion of the optical absorption coefficient is near the UV region, suggesting enhanced optical performance. The biaxial strained tuned lowbandgap values are also responsible for the high-absorption peaks near UV. These two effects get combined, resulting in efficiently utilized solar spectra by the proposed HBLs.

Conclusions 4.

In this report, the novel 2D ZnO/SiC vdWHs by dint of firstprinciples density functional theory are thoroughly studied.

Phonon dispersions and binding energy of ZnO/SiC show dynamic stability and chemical formidability. Stacked patterns have direct bandgaps of 2.86 eV for pattern-I and 2.74 eV for pattern-II as obtained with the HSE-06. Biaxial strain tailored the bandgap, and the edges and initiate UV to visible shifting, through bandgap lowering, resulting in a high photogenerated carrier for photocatalysis. The bandgap-lowering nature is monotonic from compressive to tensile strains. The intrinsic optical absorption peak is achieved at $\sim 10^5$ cm⁻¹ comparable with efficient optoelectronic materials. Biaxial strains introduce the enhancement of optical absorption and UV to visible shifting, facilitating the photocatalytic activity. Concisely, the findings we have obtained for SiC/ZnO vdWHs are indicative of the potential application of this material in efficient photocatalytic water-splitting technology.

Conflicts of interest

There are no conflicts to declare.

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